Amendment

Please amend the claims as specified herein.

- 1-9. (cancelled)
- 10. (currently amended) A process of forming a three layered thin film composite solid suitable for use as an electrolyte comprising the steps of:
- a. tape casting a series of sheets or films, each said sheet formed from <u>one</u> of at least two slip composites, <u>each said slip composite containing an electrolyte where the electrolyte of each said slip composite has a coefficient of thermal expansion ("CTE") and said <u>CTE of each said electrolyte in each said slip composites is identical within +/- 5%, wherein one of said slip composites is formed with an <u>added</u> combustible pore former <u>added</u> (a "Porous Material"), and another of said slip composites is formed without said pore former material (a "Non Porous Material");</u></u>
- b. laminating said series of sheets to create a layered structure having at least three layers, where said three layers series of layers alternate between layers formed constructed from said Non-Porous Materials and layers formed constructed from said Porous Materials; and
- c. sintering said three layered structure to a suitable temperature to densify said layer formed from said Non Porous Material to create an ionically conductive layer.
- 11. (previously presented) The process of claim 10 wherein said sintering step is performed at temperatures at or below about 1500 °C.
- 12. (previously presented) The process of claim 10 wherein said sintering step is performed at temperatures at or below about 1600 °C.
- 13. (currently amended) The process of claim 10 wherein said sintering step is performed without encapsulation of said three layered structure.

- 14. (currently amended) The process of claim 10 wherein said sintering step includes the substep of raising the temperature to a first temperature, wherein said first temperature is sufficient to combust said pore former material, and then raising said temperature to a final temperature, wherein said final temperature is sufficient to densify said layer <u>formed</u> constructed from said Non-Porous Materials.
- 15. (currently amended) The process of claim 14 wherein said substep of raising the temperature to a first temperature is undertaken at a rate to allow gases generated from combustion of said pore former to escape said three layered structure without delaminating said three layered structure in whole or in part.
- 16. (currently amended) The process of claim 12 wherein said step of sintering includes the step of raising the temperature to a first temperature suitable to allow combustion of said pore former; then raising said temperature to a second <u>intermediate</u> take off temperature, then raising the temperature to a final sintering temperature, wherein the rate of temperature rise from said second <u>intermediate</u> temperature to said final sintering temperature is at least about 10 °C /minute.
- 17. (currently amended) The process of claim 10 wherein said electrolyte slips is further comprised composed of β "-Al₂O₃ or β -Al₂O₃ or mixtures thereof.
- 18. (currently amended) The process of claim 10 wherein said electrolyte is slips are further composed comprised of NASICON.
- 19. (previously presented) The process of claim 10 wherein the thickness of said layers formed from Non-Porous Materials, after sintering, are less than 100 microns.
- 20. (previously presented) The process of claim 10 wherein the thickness of said layers formed from Porous Materials is greater than about 100 microns.

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- 21. (previously presented) The process of claim 20 wherein said thickness of said layers formed from Porous Materials is sufficient to provide structural support to said thin film composite solid. 22-25. (canceled)
- 26. (new) The process of claim 10 wherein each of said slip composites contains a binder.
- 27. (new) The process of claim 10 wherein each of said slip composites contains a plasticizer.
- 28. (new) The process of claim 10 wherein at least one of said layers formed of said Porous Material are laminated from a plurality of said sheets formed from said Porous Material.
- 29. (new) The process of claim 10 wherein at least one of said layers formed from said Non Porous Material are laminated from a plurality of said sheets formed from said Non Porous Material.
- 30. (new) The process of claim 19 wherein the thickness of said layers formed from said Non Porous Material, after sintering, is less than 50 microns.
- 31. (new) The process of claim 16, wherein said second intermediate temperature is in the range of about 1200-1275°C, and said final temperature is in the range of about 1,500 1,600°C.
- 32. (new) The process of claims 16 wherein the rate of temperature rise from said second intermediate temperature to said final sintering temperature is at least about +25 °C /minute once said temperature is about 1275 °C.
- 33. (new) The process of claim 32 further including the step of lowering said temperature from said final sintering temperature to about said second intermediate temperature wherein the rate of temperature drop from said final sintering temperature to said second intermediate temperature is at least about 25 °C /minute until said temperature is about 1275 °C.

34. (new) The process of claim 33 wherein said step of lowering said temperature from said final sintering temperature to about said second intermediate temperature takes place at a rate of temperature drop in a range of least about 10-30°C /minute until said temperature is about 1275 °C.